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(71)Applicant : KANEGAFUCHI CHEM IND CO  
LTD

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(72)Inventor : YOKOYAMA MASAO  
NODA KOJI

### (54) CURABLE COMPOSITION FOR SOLID ELECTROLYTE AND SOLID POLYELECTROLYTE

(57)Abstract:

PURPOSE: To obtain the subject composition, containing an alkenyl group- containing compound, a compound having plural hydrosilyl groups, a hydrosilylating catalyst and an alkali metallic salt, capable of providing cured products excellent in stability, uniformity, flexibility and adhesion and useful as cells, batteries, etc.

CONSTITUTION: The objective curable composition for solid electrolytes is obtained by blending (A) a compound (e.g. 1,9-decadiene) having at least one alkenyl group in the molecule with (B) a compound (e.g. cyclic polyhydrogensiloxane) having at least two hydrosilyl groups in the molecule, (C) a hydrosilylating catalyst (e.g. a solution of chloroplatinic acid catalyst in ethanol/1,2-dimethoxyethane) and (D) an alkali metallic salt prepared by combination of alkali metallic cations such as Li<sup>+</sup>, Na<sup>+</sup> or K<sup>+</sup> with anions such as F<sup>-</sup>, Cl<sup>-</sup>, I<sup>-</sup>, ClO<sub>4</sub><sup>-</sup>, BF<sub>4</sub><sup>-</sup>, PF<sub>6</sub><sup>-</sup>, SbF<sub>4</sub><sup>-</sup>, HCOO<sup>-</sup>, RCOO<sup>-</sup> (R is alkyl) or CF<sub>3</sub>SO<sub>3</sub><sup>-</sup>. The resultant composition is excellent in uniformity and flexibility and capable of providing a thin type.

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